Correction: Atomic layer deposition of a MoS$_2$ film

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(1) There is an error to the existing author list. The correct list should be:

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(2) There is an error in the Acknowledgements. It should read:

We thank the Institute of Materials Research and Engineering under the Agency for Science, Technology and Research (A*STAR) Singapore as well as the Singapore-Berkeley Research Initiative for Sustainable Energy (SinBeRISE) CREATE Program for the financial support. We are grateful to Mr Lim Poh Chong for his assistance in XRD, Ms June Ong for her assistance in XPS and Dr Liu Hong Fei and Dr Jia Min Chin for their advice.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.